CLAIMS

- 1. A gallium-nitride-based light-emitting apparatus comprising:
- 5 a substrate;

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a first-conducting-type clad layer formed on the substrate; an active layer formed on the clad layer; and

a second-conducting-type clad layer formed on the active layer,

the active layer including barrier layers and well layers made of a gallium-nitride-based compound semiconductor, wherein

the barrier layers of the active layer include a first barrier layer formed toward the first-conducting-type clad layer and second barrier layers sandwiched by the well layers,

the light-emitting apparatus comprises a second-conducting-type carrier block layer between the active layer and the second-conducting-type clad layer, and

the band gap Egb of the carrier block layer, the band gap Eg2 of the second barrier layer, the band gap Eg1 of the first barrier layer and the band gap Egc of the clad layers satisfy the relationship Egb > Eg2 > Eg1 \ge Egc.

- 2. A gallium-nitride-based light-emitting apparatus according to claim 1, wherein the thickness d1 of the first barrier layer and the thickness d2 of each of the second barrier layers satisfy the relationship d1 > d2.
- 3. A gallium-nitride-based light-emitting apparatus according to claim 2, wherein the thickness d1 of the first barrier layer

satisfies the relationship d1 \leq 50 nm.

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- 4. A gallium-nitride-based light-emitting apparatus according to claim 1 or 2, wherein the thickness d3 of each of the well layers satisfies that the relationship d3 \leq 4 nm.
- 5. A gallium-nitride-based light-emitting apparatus according to any one of claims 1 to 4, wherein the first barrier layer and the second barrier layers comprise $Al_xIn_yGa_{1-x-y}N$ (0 \leq x \leq 0.3 and 0 \leq y \leq 0.05), and wherein the well layers comprise $Al_aIn_bGa_{1-a-b}N$ (0 \leq a \leq 0.01 and 0 \leq b \leq 0.1).
- 6. A gallium-nitride-based light-emitting apparatus according to any one of claims 1 to 5, wherein the carrier block layer comprises $Al_pIn_qGa_{1-p-q}N \ (0 \le p \le 0.5 \ and \ 0 \le q \le 0.1) \, .$
- 7. A gallium-nitride-based light-emitting apparatus according to any one of claims 1 to 6, wherein the clad layers comprise a super-lattice structure formed by stacking layers of $\mathrm{Al}_{\alpha}\mathrm{In}_{\gamma}\mathrm{Ga}_{1-20}$ $\alpha_{-\gamma}\mathrm{N}$ (0 $\leq \alpha \leq$ 0.2 and 0 $\leq \gamma \leq$ 0.1) and layers of $\mathrm{Al}_{\beta}\mathrm{In}_{\gamma}\mathrm{Ga}_{1-\beta-\gamma}\mathrm{N}$ (0 $\leq \beta \leq$ 0.05 and 0 $\leq \gamma \leq$ 0.1).